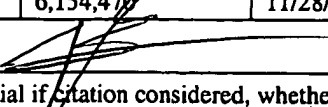


Form PTO 1449 (Rev. 2-32) U.S. Department of Commerce Patent and Trademark Office				Atty. Docket No. LMPY-11310		Serial No. 09/771,013	
Information Disclosure Statement by Applicant (Use several sheets if necessary)				Applicant: Klaus Vogler, et al.			
				Filed: January 25, 2001 Group: 2881			
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Klaus Vogler, et al.

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